



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:)
Inventors: Joshi et al.) ATTORNEY FILE NO.:
Serial No.: 10/812,591) SLA0786
Filed: March 29, 2004)
Title: HIGH DENSITY PLASMA) Customer No.: 55,286
PROCESS FOR THE) Group Art: 2891
FORMATION OF SILICON) Confirmation No.: 2314
DIOXIDE ON SILICON)
CARBIDE SUBSTRATES)

Mail Stop Issue Fee
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

ISSUE FEE RESPONSE

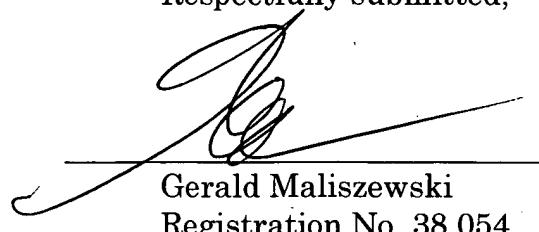
This paper is responsive to a Notice of Allowance mailed on June 8, 2006. Enclosed are:

two copies of the Issue Fee Transmittal form;
6 sheets of Replacement drawings; and,
a PTO-2038 form, in the amount of \$1709.

REMARKS

The Applicant neither expressly agrees nor disagrees with the stated reasons for the allowance of the claims.

Respectfully submitted,


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